



DATE: April 14, 1995  
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 FROM: K. Sahu/300.1 1,5  
 SUBJECT: Radiation Report on: MIC4429  
           Project: CASSINI/CIRS  
           Control #: 11820  
           Job #: EE56098  
           Project part #: 5962-8877002PA

PPM-95-142

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A radiation evaluation was performed on MIC4429 (High Speed, High Current, MOSFET Driver) to determine the total dose tolerance of these parts. A brief summary of the test results is provided below. For detailed information, refer to Tables I through IV and Figure 1.

The total dose testing was performed using a <sup>60</sup>Co gamma ray source. During the radiation testing, four parts were irradiated under bias (see Figure 1 for bias configuration), and one part was used as a control sample. The total dose radiation levels were 2.5, 5, 10, 15, 20, 30, 50 and 100 krad\*. The dose rate was between 0.08 and 2.94 krad/hour, depending on the total dose level (see Table II for radiation schedule). After the 100 krad irradiation, the parts were annealed for 168 hours at 25°C, after which the parts were annealed for 168 hours at 100°C. After the radiation exposure and annealing treatment, parts were electrically tested according to the test conditions and the specification limits\*\* listed in Table III. These tests included four functional tests at 50.0 kHz.

All parts passed initial electrical measurements. All irradiated parts passed all functional and parametric tests up to and including the 15 krad irradiation level.

At the 20 krad level, all irradiated parts failed Functional Test # 2, in which  $V_{cc} = 4.5$  V,  $V_{il} = 0.8$  V and  $V_{ih} = 2.4$  V. However, all parts passed Functional Test # 1, in which  $V_{cc} = 4.5$  V,  $V_{il} = 0.0$  V and  $V_{ih} = 2.4$  V. This indicates that the parts were becoming sensitive to the  $V_{il}$  level. Parts continued to pass both functional tests in which  $V_{cc} = 15.0$  V. In addition, all irradiated parts failed the VOH45\_2 test, in which  $V_{il} = 0.8$  V, indicating an incorrect output state. However, the parts continued to pass VOH45\_1, in which  $V_{il} = 0.0$  V. At the 30 krad level, the same failures were observed.

At the 50 krad level, all irradiated parts failed Functional Tests # 2 and # 4. In both of these tests,  $V_{il} = 0.8$  V. Parts continued to pass both Functional Test # 1 and # 3, in which  $V_{il} = 0.0$  V. The same failures in VOH45\_2 continued.

At the 100 krad level, the same failures were observed. All irradiated parts continued to pass all other functional and parametric tests.

After annealing for 168 hours at 25°C, no recovery was observed. In addition, S/N 12 and 13 failed VOH15\_2, in which  $V_{il} = 0.8$  V, indicating an incorrect output state. After annealing for 168 hours at 100°C, no rebound effects were observed.

Table IV provides a summary of the functional test results and the mean and standard deviation values for each parameter after the irradiation exposure and annealing.

\* The term rads, as used in this document, means rads(silicon). All radiation levels cited are cumulative.

\*\* These are manufacturer's pre-irradiation data specification limits. No post-irradiation limits were provided by the manufacturer at the time these tests were performed.

Any further details about this evaluation can be obtained upon request. If you have any questions, please call me at (301) 731-8954.

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Figure 1. Radiation Bias Circuit for MIC4429

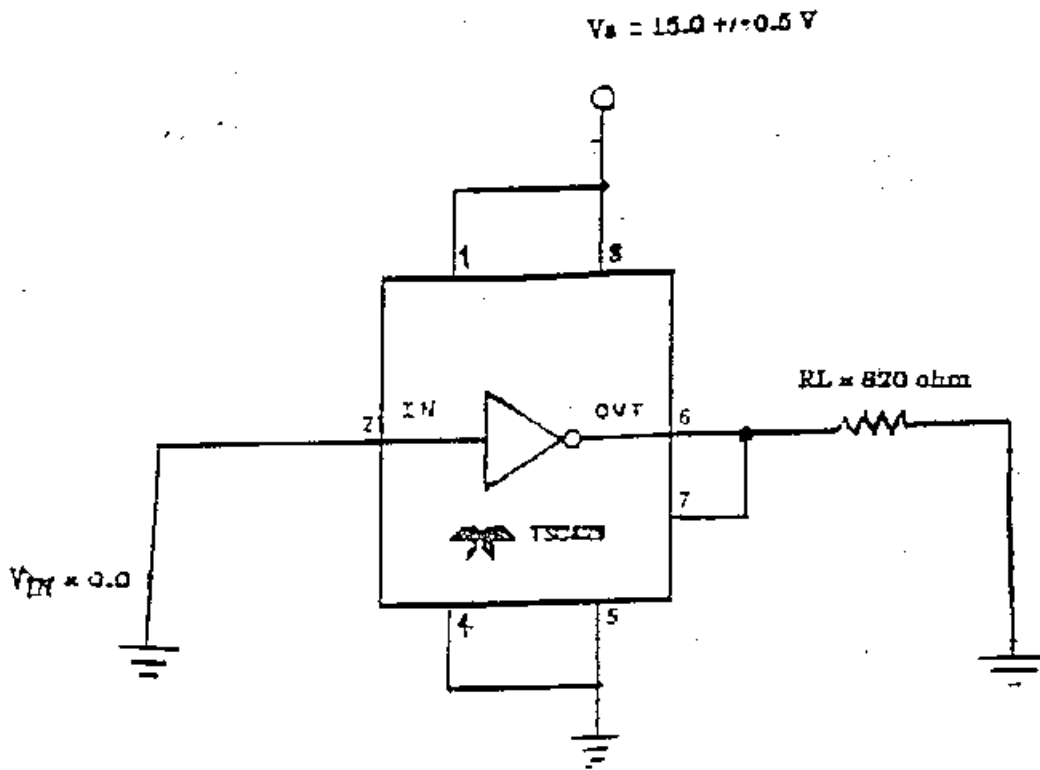


TABLE I. Part Information

Generic Part Number:	MIC4429*
CASSINI/CIRS Part Number	5962-8877002PA
CASSINI/CIRS Control Number:	11820
Charge Number:	FF56098
Manufacturer:	Micrel
Lot Date Code (LDC):	9418
Quantity Tested:	5
Serial Number of Control Samples:	11
Serial Numbers of Radiation Samples:	12, 13, 14, 15
Part Function:	High Speed, High Current MOSFET Driver
Part Technology:	MOSFET
Package Style:	8-pin DIP
Test Equipment:	S-50
Engineer:	T. Mondy

\* No radiation tolerance/hardness was guaranteed by the manufacturer for this part.

TABLE II. Radiation Schedule for MIC4429.

EVENT .....	DATE
1) INITIAL ELECTRICAL MEASUREMENTS .....	02/15/95
2) 2.5 KRAD IRRADIATION (0.16 KRADS/HOUR) .....	02/21/95
POST-2.5 KRAD ELECTRICAL MEASUREMENT .....	02/22/95
3) 5 KRAD IRRADIATION (0.16 KRADS/HOUR) .....	02/22/95
POST-5 KRAD ELECTRICAL MEASUREMENT .....	02/23/95
4) 10 KRAD IRRADIATION (0.33 KRADS/HOUR) .....	02/23/95
POST-10 KRAD ELECTRICAL MEASUREMENT .....	02/24/95
5) 15 KRAD IRRADIATION (0.08 KRADS/HOUR) .....	02/24/95
POST-15 KRAD ELECTRICAL MEASUREMENT .....	02/27/95
6) 20 KRAD IRRADIATION (0.33 KRADS/HOUR) .....	02/27/95
POST-20 KRAD ELECTRICAL MEASUREMENT .....	02/28/95
7) 30 KRAD IRRADIATION (0.67 KRADS/HOUR) .....	02/28/95
POST-30 KRAD ELECTRICAL MEASUREMENT .....	03/08/95
8) 50 KRAD IRRADIATION (1.00 KRAD/HOUR) .....	03/08/95
POST-50 KRAD ELECTRICAL MEASUREMENT .....	03/09/95
9) 100 KRAD IRRADIATION (2.94 KRAD/HOUR) .....	03/09/95
POST-100 KRAD ELECTRICAL MEASUREMENT .....	03/10/95
10) 168-HOUR ANNEALING @25°C .....	03/10/95
POST-168 HOUR ANNEAL ELECTRICAL MEASUREMENT .....	03/17/95
11) 168-HOUR ANNEALING @100°C .....	03/17/95
POST-168 HOUR ANNEAL ELECTRICAL MEASUREMENT .....	03/27/95

PARTS WERE IRRADIATED AND ANNEALED UNDER BIAS; SEE FIGURE 1.

Table III. Electrical Characteristics of MIC4429

FUNCTIONAL TESTS

Test #	Test Conditions
FUNC1	V <sub>cc</sub> =4.5V, V <sub>il</sub> =0.0V, V <sub>ih</sub> =2.4V, Freq.=50.0kHz
FUNC2	V <sub>cc</sub> =4.5V, V <sub>il</sub> =0.8V, V <sub>ih</sub> =2.4V, Freq.=50.0kHz
FUNC3	V <sub>cc</sub> =15 V, V <sub>il</sub> =0.0V, V <sub>ih</sub> =5.0V, Freq.=50.0kHz
FUNC4	V <sub>cc</sub> =15 V, V <sub>il</sub> =0.8V, V <sub>ih</sub> =2.4V, Freq.=50.0kHz

PARAMETRIC TESTS

Test #	Parameter	Units	Test Conditions	Spec. Limits	
				Min	Max
1	IINH1	μA	V <sub>cc</sub> =4.5V, V <sub>in</sub> =4.5V	-10.0	10.0
2	IHN2	μA	V <sub>cc</sub> =15V, V <sub>in</sub> =15V	-10.0	10.0
3	IINL1	μA	V <sub>cc</sub> =4.5V, V <sub>in</sub> =0V	-10.0	10.0
4	IINL2	μA	V <sub>cc</sub> =15V, V <sub>in</sub> =0V	-10.0	10.0
5	VOH45 1	V	V <sub>il</sub> =0.0V, V <sub>ih</sub> =4.0V, V <sub>cc</sub> =4.5V	4.475	-
6	VOH45 2	V	V <sub>il</sub> =0.8V, V <sub>ih</sub> =2.4V, V <sub>cc</sub> =4.5V	4.475	-
7	VOH15 1	V	V <sub>il</sub> =0.0V, V <sub>ih</sub> =4.0V, V <sub>cc</sub> =15V	14.98	-
8	VOH15 2	V	V <sub>il</sub> =0.8V, V <sub>ih</sub> =2.4V, V <sub>cc</sub> =15V	14.98	-
9	VOL45 1	mV	V <sub>il</sub> =0.8V, V <sub>ih</sub> =2.4V, V <sub>cc</sub> =4.5V	-	25.00
10	VOL45 2	mV	V <sub>il</sub> =0.0V, V <sub>ih</sub> =4.0V, V <sub>cc</sub> =4.5V	-	25.00
11	VOL15 1	mV	V <sub>il</sub> =0.0V, V <sub>ih</sub> =4.0V, V <sub>cc</sub> =15V	-	25.00
12	VOL15 2	mV	V <sub>il</sub> =0.8V, V <sub>ih</sub> =2.4V, V <sub>cc</sub> =15V	-	25.00
13	ROUT1	Ω	V <sub>il</sub> =0.0V, V <sub>ih</sub> =4.5V, V <sub>cc</sub> =15V	-	2.800
14	ROUT0	Ω	V <sub>il</sub> =0.0V, V <sub>ih</sub> =4.5V, V <sub>cc</sub> =15V	-	2.500
15	ICC1	mA	V <sub>cc</sub> =4.5V, V <sub>in</sub> =3.0V	-	1.500
16	ICC0	μA	V <sub>cc</sub> =1.5V, V <sub>in</sub> =0.0V	-	150.0
17	TD1	ns	V <sub>cc</sub> =15V, C <sub>load</sub> =2500pF, V <sub>in</sub> =0.4, 5.0V	2.000	60.00

TABLE IV: Summary of Electrical Measurements After Total Dose Exposures and Annealing for MIC4429 /1

#	Functional Test/3	Spec. Lim./3	Total Dose Exposure (krads)												Annealing							
			Initial		2.5		5		10		15		20		30		50		100		168 hrs@150°C	
			mean	sd	mean	sd	mean	sd	mean	sd	mean	sd	mean	sd	mean	sd	mean	sd	mean	sd	mean	sd
1	Func1, Voh@5V, Voh@15V, Voh@25V, Voh@50V, Voh@100V, Voh@150V, Voh@200V	10.0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0
2	Func2, Voh@5V, Voh@15V, Voh@25V, Voh@50V, Voh@100V, Voh@150V, Voh@200V	10.0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0
3	Func3, Voh@5V, Voh@15V, Voh@25V, Voh@50V, Voh@100V, Voh@150V, Voh@200V	10.0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0
4	Func4, Voh@5V, Voh@15V, Voh@25V, Voh@50V, Voh@100V, Voh@150V, Voh@200V	10.0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0
5	VOH45_1/4	4.475	-	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50
6	VOH45_2/5	4.475	-	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50	0	4.50
7	VOH15_1/4	14.98	-	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0
8	VOH15_2/5	14.98	-	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0	0	15.0
9	VOL45_1	25.00	-	25.00	0.03	25.00	0.06	25.00	0.11	25.00	0.16	25.00	0.21	25.00	0.26	25.00	0.31	25.00	0.36	25.00	0.41	25.00
10	VOL45_2/4	25.00	-	25.00	0.03	25.00	0.06	25.00	0.11	25.00	0.16	25.00	0.21	25.00	0.26	25.00	0.31	25.00	0.36	25.00	0.41	25.00
11	VOL15_1/4	25.00	-	25.00	0.06	25.00	0.10	25.00	0.14	25.00	0.18	25.00	0.22	25.00	0.26	25.00	0.30	25.00	0.34	25.00	0.38	25.00
12	VOL15_2	25.00	-	25.00	0.06	25.00	0.10	25.00	0.14	25.00	0.18	25.00	0.22	25.00	0.26	25.00	0.30	25.00	0.34	25.00	0.38	25.00
13	ROUT1	0	-	2.800	1.48	2.800	1.48	2.800	1.48	2.800	1.48	2.800	1.48	2.800	1.48	2.800	1.48	2.800	1.48	2.800	1.48	2.800
14	ROU10	0	-	2.500	2.21	2.500	2.21	2.500	2.21	2.500	2.21	2.500	2.21	2.500	2.21	2.500	2.21	2.500	2.21	2.500	2.21	2.500
15	ICCI	mA	-	1.500	0.37	1.500	0.37	1.500	0.37	1.500	0.37	1.500	0.37	1.500	0.37	1.500	0.37	1.500	0.37	1.500	0.37	1.500
16	ICCO	µA	-	150.0	65.3	150.0	65.3	150.0	65.3	150.0	65.3	150.0	65.3	150.0	65.3	150.0	65.3	150.0	65.3	150.0	65.3	150.0
17	TD1	ms	2.000	60.00	16.3	60.00	16.3	60.00	16.3	60.00	16.3	60.00	16.3	60.00	16.3	60.00	16.3	60.00	16.3	60.00	16.3	60.00

- Notes:
- 1/ The mean and standard deviation values were calculated over the four parts irradiated in this testing. The control sample remained constant throughout the testing and is not included in this table.
  - 2/ "P" indicates that all parts passed this test at this irradiation or annealing level. "F" indicates that all parts failed this test at this irradiation or annealing level. "nPmF" indicates that n parts passed and m parts failed this test at this irradiation or annealing level.
  - 3/ These are manufacturer's pre-irradiation data sheet specification limits. No post-irradiation limits were provided by the manufacturer at the time the tests were performed.
  - 4/ These tests were added after the 20 krad irradiation and testing. The purpose of adding these tests was to determine if the parts would pass VOH tests under hard input conditions (Vil = 0.0 V, Vih = 4.0 V), since the parts had started failing VOH45\_2 under soft input conditions.
  - 5/ No valid readings could be obtained for failing parts at these irradiation or annealing levels, therefore, data are given as "nPmF", as in Note 2.